

L Number	Hits	Search Text	DB	Time stamp
2	48	electro adj chemical adj polish\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/01 18:44
3	575	electrolytic and wiper	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/01 18:44
4	60	(electrolytic and wiper) and polish\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/01 18:49
5	6750	anode and cathode and polish\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/01 19:20
6	75	(anode and cathode and polish\$3) and 451/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/01 19:09
8	798	(anode and cathode and polish\$3) and 438/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/01 19:19
7	132	(anode and cathode and polish\$3) and 216/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/01 19:10
9	170	((anode and cathode and polish\$3) and 438/\$.ccls.) and pulse	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/01 19:17
10	6	((anode and cathode and polish\$3) and 438/\$.ccls.) and pulse adj voltage	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/01 19:17
11	4	((anode and cathode and polish\$3) and 438/\$.ccls.) and variable adj voltage	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/01 19:18
12	10	((anode and cathode and polish\$3) and 438/\$.ccls.) and (variable or pulse) adj voltage	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/01 19:19
13	192	(anode and cathode and polish\$3) and (pulse or variable) adj voltage	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/01 19:22
14	134	((anode and cathode and polish\$3) and (pulse or variable) adj voltage) not plating	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/01 19:22